

Please amend the Abstract of the Disclosure as follows:

~~The invention provides a~~ A method for the patterned coating of a substrate ~~(1)~~ with at least one surface ~~(2)~~ ~~which is to be coated, which~~ is provided. The method is suitable for the rapid and inexpensive production of precise patterns. ~~For this purpose, the~~ The method comprises includes the steps of: producing at least one negatively patterned first coating ~~(3, 31, 32)~~ on the at least one surface ~~(2)~~, depositing at least one second layer ~~(7, 71, 72, 73)~~, which includes a material with a vitreous structure, on the surface ~~(2)~~ ~~which has been provided with the first coating (3, 31, 32),~~ and at least partially removing the first coating ~~(3, 31, 32)~~.